

US00D756220S

(12)

United States Design Patent
Park

(10) Patent No.:

US D756,220 S

(45) Date of Patent:

** May 17, 2016

(54) NAIL POLISH APPLICATOR HANDLE

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(**) Term: 14 Years

(21) Appl. No.: 29/502,438

(22) Filed: Sep. 16, 2014

(51) LOC (10) Cl. 09-07

(52) U.S. Cl. USPC D9/452

(58) Field of Classification Search
USPC D9/434, 435, 436, 440, 447, 452, 454, D9/499; D4/114, 127, 135, 138; D28/7; 220/376; 401/129
CPC B65D 62/32; A45D 40/265
See application file for complete search history.

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(57) CLAIM

The ornamental design for a nail polish applicator handle, as shown and described.

DESCRIPTION

FIG. 1 is a perspective view of my design;
FIG. 2 is a front elevational perspective view thereof; and,
FIG. 3 is a top plan view thereof.
The broken line showing illustrates environment only and forms no part of the claimed design.

1 Claim, 2 Drawing Sheets

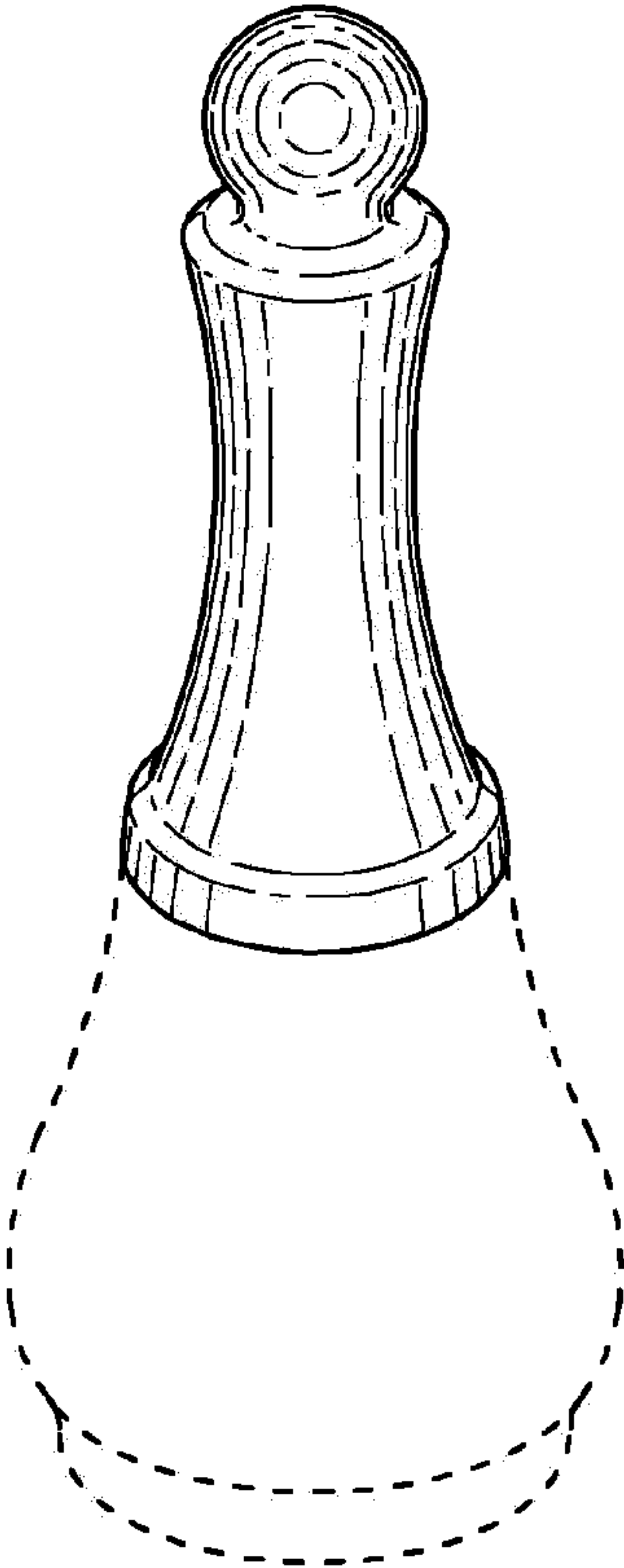


FIG. 1

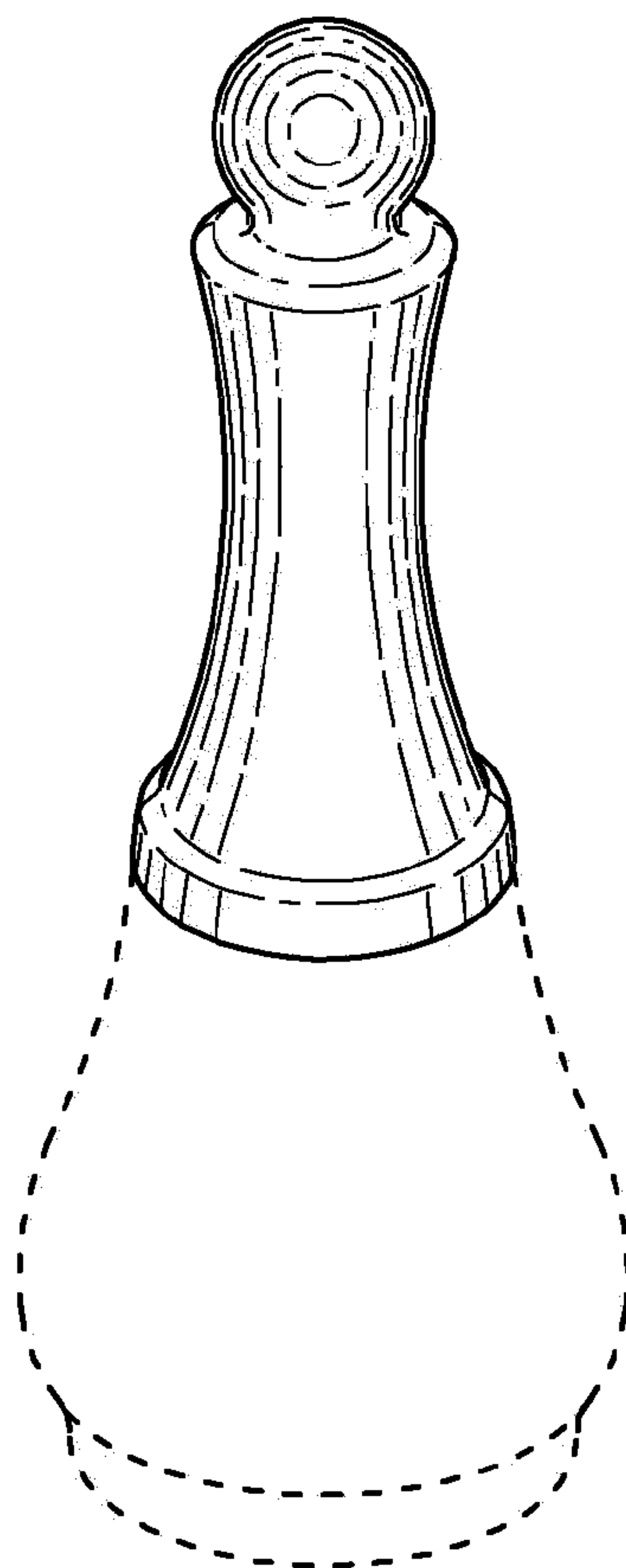


FIG. 2

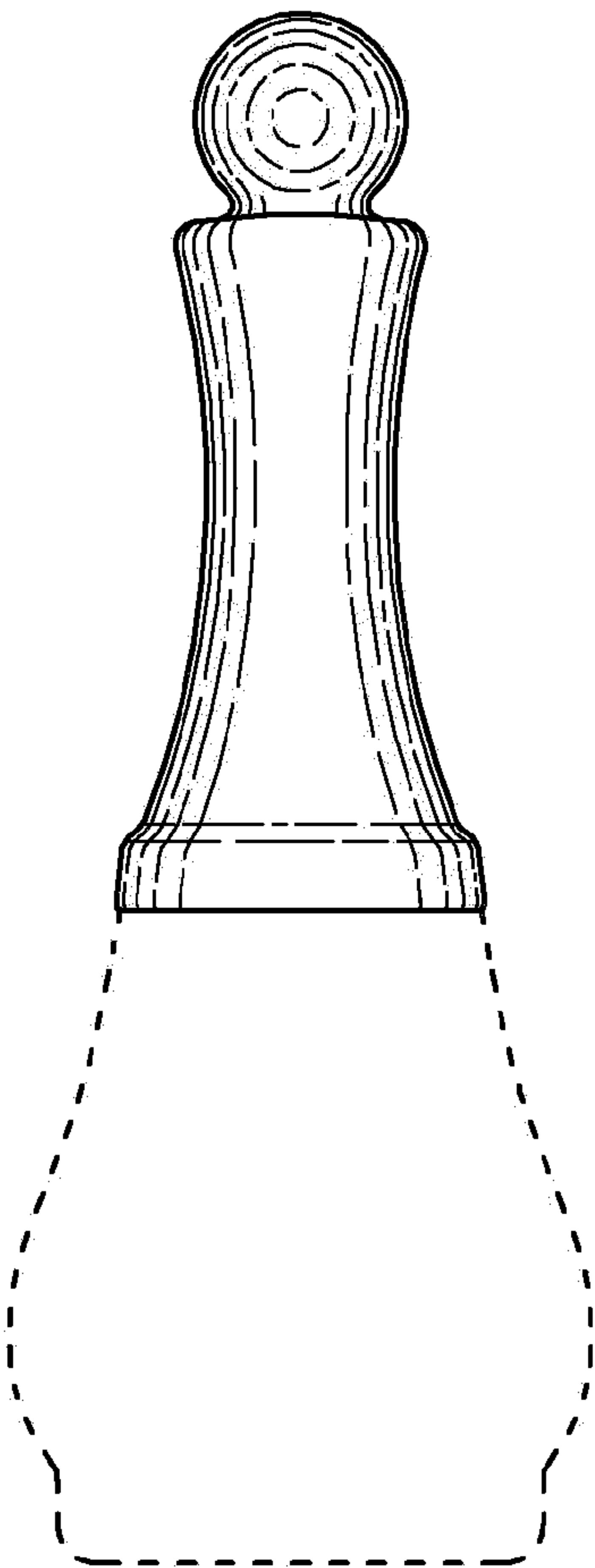


FIG. 3

